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	Application No.	Applicant(s)
	10/702,555	HUANG ET AL.
Notice of Allowability	Examiner	Art Unit
	John A. McPherson	1756
The MAILING DATE of this communication appearable claims being allowable, PROSECUTION ON THE MERITS IS nerewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R	(OR REMAINS) CLOSED in or other appropriate commu GHTS. This application is so and MPEP 1308.	this application. If not included nication will be mailed in due course. THIS
. X This communication is responsive to the Applicantion filed	<u>11/7/03</u> .	
2. X The allowed claim(s) is/are <u>1-8</u> .		
a)  Acknowledgment is made of a claim for foreign priority unally All b)  Some* c)  None of the:  1.  Certified copies of the priority documents have 2.  Certified copies of the priority documents have 3.  Copies of the certified copies of the priority documents have 1.  Certified copies of the priority documents have 2.  Certified copies of the certified copies of the priority documents have 3.  Copies of the certified copies of the priority documents have 1.  Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  4.  A SUBSTITUTE OATH OR DECLARATION must be submained in the submained priority in the priority of the Notice of Draftspers 1.  CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1.  Paper No./Mail Date  (b) including changes required by the attached Examiner's Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the certified copies of the priority documents and the deposition of the depos	e been received. e been received in Application cuments have been received of this communication to file IENT of this application. eitted. Note the attached EXA as reason(s) why the oath or set be submitted. eson's Patent Drawing Review of Samendment / Comment or 1.84(c)) should be written on the header according to 37 CFI sit of BIOLOGICAL MATE	in No  In this national stage application from the a reply complying with the requirements  MINER'S AMENDMENT or NOTICE OF declaration is deficient.  ( PTO-948) attached  in the Office action of  e drawings in the front (not the back) of R 1.121(d).  ERIAL must be submitted. Note the
Attachment(s) . ☑ Notice of References Cited (PTO-892) . ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  S. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date 11/7/03  S. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Su Paper No./I 98), 7. ☑ Examiner's /	ormal Patent Application (PTO-152) Immary (PTO-413), Mail Date Amendment/Comment Statement of Reasons for Allowance

## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Joe McKinney Muncy on 5/26/06.

The application has been amended as follows:

In claim 1, line 1, "the" has been deleted, and --an-- substituted therefore.

In claim 2, line 2, the second occurrence of "the" (i.e. before the word *electroforming*) has been deleted, and --an-- substituted therefore.

Claims 9-12, drawn to a non-elected invention with traverse, have been canceled.

## Pertinent Prior Art

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

US 7,014,987 discloses a manufacturing method of a liquid jet head comprising the steps of forming a separating layer on a substrate, forming a first coat resin layer on the separating layer, exposing the first coat resin layer utilizing a mask to prepare a latent image of liquid discharge ports, forming and patterning a soluble resin layer,

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forming a second coat resin layer on the patterned soluble resin layer, forming bond portions on the second coat resin layer, bonding a piezoelectric element to the bond portions, eluting the separating layer to separate the substrate, eluting the latent image to form the liquid discharge ports, eluting the soluble pattern resin layer to form liquid flow paths, bonding liquid supply members, and electrically bonding a signal line and a common line for driving the piezoelectric element. See column 7, line 15 to column 9, line 20.

US 5,229,785 discloses a method of manufacturing a thermal inkjet printhead having a plastic orifice plate comprising the steps of providing a dummy substrate, forming a plastic orifice member on the dummy substrate, forming an insulating barrier layer provided with a plurality of firing chambers on the plastic orifice plate, depositing a thin film resistor substrate provided with a plurality of heater resistors on the barrier layer, and removing the dummy substrate from the composite structure using photoresist lift off techniques. See the abstract.

## Allowable Subject Matter

The following is an examiner's statement of reasons for allowance:

In a manufacturing method of a component for an inkjet printhead comprising the steps of providing a substrate; forming a sacrifice layer on a surface of the substrate; forming a first photosensitive polymer layer on the structure provided above; forming more than one orifice on the first photosensitive layer by photolithography, the orifices allowing a fluid to flow through; and removing the sacrifice layer so that the

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photosensitive polymer layer departs form the substrate, the prior art does not teach or suggest the method further comprising the steps of forming a metal conductive circuit on the sacrifice layer, such that the first photoresist layer is formed on the metal conductive circuit, and forming more than one through hole on the first photosensitive layer by photolithography, with the through holes being exposed from a lead end of the metal conductive circuit.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John A. McPherson whose telephone number is (571) 272-1386. The examiner can normally be reached on Monday through Friday, 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on (571) 272-1385. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. Application/Control Number: 10/702,555

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